



INTERNATIONAL
GEMOLOGICAL
INSTITUTE

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LABORATORY GROWN DIAMOND REPORT

January 10, 2026

IGI Report Number

Description

Shape and Cutting Style

Measurements

GRADING RESULTS

Carat Weight

Color Grade

Clarity Grade

ADDITIONAL GRADING INFORMATION

Polish

Symmetry

Fluorescence

Inscription(s)

Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process. Type IIa

LG764627996

Report verification at [igi.org](https://www.igi.org)

PROPORTIONS

Medium To Slightly Thick

17%

60%

48%

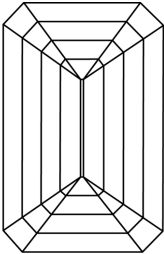
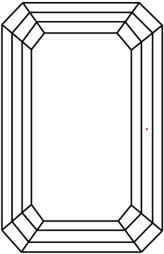
68.6%

Long



Sample Image Used

CLARITY CHARACTERISTICS



KEY TO SYMBOLS

Red symbols indicate internal characteristics.
Green symbols indicate external characteristics.

COLOR

D E F G H I J Faint Very Light Light

CLARITY

FL IF VVS ¹⁻² VS ¹⁻² SI ¹⁻² I ¹⁻³

Flawless Internally Flawless Very Very Slightly Included Very Slightly Included Slightly Included Included

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IGI Report No LG764627996

EMERALD CUT

7.95 X 5.39 X 3.70 MM

1.58 CARAT

F

VVS 2

60%

48%

68.6%

Long

Medium To Slightly Thick

EXCELLENT

EXCELLENT

NONE

IGI LG764627996

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www.igi.org

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